発行済の米国特許の訂正のための各種手続

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1. はじめに

Issued patents may be corrected or modified in <u>several</u> ways including: (1) filing a request for <u>exparte</u> reexamination of the patent; (2) filing a request for <u>inter partes</u> reexamination of the patent; (3) filing a request for a <u>reissue patent</u>; (4) filing a <u>disclaimer</u> (i.e., statutory or terminal); and (5) filing a request for a <u>certificate of correction</u>. Each of these procedures is utilized to deal with different issues which may arise after issuance of a U.S. patent. An issued patent may also be modified as the result of (6) a <u>patent interference proceeding</u> under 35 U.S.C. § 135, e.g., if some or all of its claims are canceled as the result of an adverse judgment in the patent interference proceeding (given that the interference is between a patent and application). However, interference proceedings will end, and be replaced by derivation proceedings starting on March 16, 2013 due to passage of the Leahy-Smith America Invents Act (AIA).

The <u>AIA</u> provides several new post-grant proceedings that can be filed by the patent owner or a third party, including (7) <u>post-grant review</u>, (8) <u>inter partes review</u> (which replaces <u>inter partes reexamination</u>), (9) <u>post-grant validity review of business method patents</u>, and (10) <u>supplemental examination</u>. There were no (significant) changes to <u>ex parte</u> reexamination, reissue, disclaimers and certificate of correction. The USPTO also provides information on such future <u>inter partes</u> disputes, which can be found here.

【全14頁】

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